Abstract Submitted for the MAR10 Meeting of The American Physical Society

Polarization effect on the growth of Pt thin films on PbTiO<sub>3</sub> (100) surfaces<sup>1</sup> MIGUEL ANGEL MENDEZ POLANCO, ILYA GRINBERG, WISSAM AL-SAIDI, ANDREW RAPPE, The Makineni Theoretical Laboratories, Department of Chemistry, University of Pennsylvania, Philadelphia, Pennsylvania 19104-6323, USA — Results of Density Functional Theory calculations performed on Pt thin films grown on PbTiO<sub>3</sub> (100) Ferroelectric (FE) ideal surface terminations are discussed. We analyze the effect of the ferroelectric polarization on the metal-oxide interface and how this in turn influences the growth of Pt thin films on PbTiO<sub>3</sub>. Our results suggest a preferential stacking ordering for the Pt layers that depends on the polarization of the surface: The *hollow*-top-hollow... arrangement is preferred over the *top*-hollow-top... registry for the positive (P<sup>+</sup>) polarization surface; however, this predilection is reversed for the negative (P<sup>-</sup>) polarization surface. The effect of strain in the adsorption of Pt layers will also be discussed. This polarizationdependent preference for the adsorption of Pt layers onto FE surfaces could be of interest in understanding the mechanism of polarization fatigue.

<sup>1</sup>The authors acknowledge support from the AFOSR under Grant FA9550-07-1-0397, from the DOE under Grant DE-FG02-07ER15920, and computational support from the HPCMO

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Date submitted: 23 Nov 2009

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